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Towards superconducting spintronics with RuO₂ and CrO₂ nanowires

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Towards Superconducting Spintronics
with
RuO₂ and CrO₂ Nanowires

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About the cover: The cover shows the SEM image of a CrO_2 based Josephson junction device studied in thesis. The two arrows represent the equal spin triplet pairings.

Cover design: Kumar Prateek

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To my grandparents

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